

**Search Notes**

Application No.

10/608,426

Examiner

Stephen W. Smoot

Applicant(s)

CHEONG ET AL.

Art Unit

2813

**SEARCHED**

Class	Subclass	Date	Examiner
438	639	7/24/2004	SWS
438	761	7/24/2004	SWS
438	763	7/24/2004	SWS
438	791	7/24/2004	SWS
438	792	7/24/2004	SWS
Updated	Above	2/4/2005	SWS

*S.W.S.**S.W.S.***INTERFERENCE SEARCHED**

Class	Subclass	Date	Examiner
Same as Above		2/4/2005	<i>S.W.S.</i> SWS

**SEARCH NOTES  
(INCLUDING SEARCH STRATEGY)**

	DATE	EXMR
Key Words: Bitline - Nitride Spacer, Hard Mask; Contact Hole - Landing Plug, Nitride Sidewall Liner;	7/24/2004	<i>S.W.S.</i> SWS
HDPCVD - High Density Plasma.	7/24/2004	<i>S.W.S.</i> SWS
Updated Above Search	2/4/2005	<i>S.W.S.</i> SWS
Search Tools - EAST (attached): USPAT; US PG PUBS; Derwent; EPO; JPO; IBM TDB	7/24/2004 <i>2-4-05</i>	SWS <i>S.W.S.</i>